

Electronic Acknowledgement Receipt

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Application Number:	10591718
International Application Number:	
Confirmation Number:	3280
Title of Invention:	Positive-type resist composition for liquid immersion lithography and method for forming resist pattern
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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)/ Message Digest	Multi Part /.zip	Pages (if appl.)
1	Transmittal Letter	Information_Disclosure_Statement.pdf	54482 d301c8d186c8917838e865bca194c33d86d	no	2

Warnings:

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2	Information Disclosure Statement (IDS) Filed (SB/08)	US_IDS_Form__SB_08a.pdf	776417 <small>96b9801748001a728cd8f12084ee13e1d d4c28</small>	no	4
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3	NPL Documents	Notice_of_Reasons_for_Rejection.pdf	107068 <small>48b8cccd768ac1d01813b4173d246a0f759f 5ccc</small>	no	3
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4	Foreign Reference	JP2005164821.pdf	950832 <small>53de91b26573e11eb9d81a8016ea2d7fca0 65dc</small>	no	35
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